L Number	Hits	Search Text	DB	Time stamp
-	7417	((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 14:50
-	430037	tft or (thin near2 film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 14:49
-	35286	(photoresist near2 pattern) or (photo near2 (mask or masks))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 21:57
-	9434	(tft or (thin near2 film)) and ((photoresist near2 pattern) or (photo near2 (mask or masks)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:24
-	20524	reticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:24
-	584	((tft or (thin near2 film)) and ((photoresist near2 pattern) or (photo near2 (mask or masks)))) and reticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:24
-	102	(((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.) and reticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:24
-	14668	(ldd or (lightly near2 (doped adj drain)) near2 region)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:26
-	8	(((((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.) and reticle) and ((ldd or (lightly near2 (doped adj drain)) near2 region))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:27
-	639	((tft or (thin near2 film)) and ((photoresist near2 pattern) or (photo near2 (mask or masks)))) and ((ldd or (lightly near2 (doped adj drain)) near2 region))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:27
-	81	(((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.) and (((tft or (thin near2 film)) and ((photoresist near2 pattern) or (photo near2 (mask or masks)))) and ((ldd or (lightly near2 (doped adj drain)) near2 region)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:27
-	0	6548331.URPN.	USPAT	2004/01/09 21:37
-	11	("5403772" | "5488000" | "5569610" | "5581092" | "5821562" | "6066547" | "6097037" | "6133073" | "6221702" | "6278130" | "6300659").PN.	USPAT	2004/01/09 21:37
-	0	6440784.URPN.	USPAT	2004/01/09 21:38

-	14	("4514253" | "4654117" | "5627103" | "5686326" | "5714790" | "5733804" | "5909615" | "5917199" | "5940151" | "6166785" | "6204520" | "6232158" | "6275275" | "6337234").PN.	USPAT	2004/01/09 21:38	
-	14	("4514253" | "4654117" | "5627103" | "5686326" | "5714790" | "5733804" | "5909615" | "5917199" | "5940151" | "6166785" | "6204520" | "6232158" | "6275275" | "6337234").PN.	USPAT	2004/01/09 21:40	
-	7	5668019.URPN.	USPAT	2004/01/09 21:41	
-	7	("4479831" | "4577391" | "4629859" | "4727044" | "4751169" | "4980018" | "5214295").PN.	USPAT	2004/01/09 21:43	
-	5054	t near2 gate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:44	
-	634	(t near2 gate) and (tft or (thin near2 film))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:45	
-	87	((t near2 gate) and (tft or (thin near2 film))) and ((ldd or (lightly near2 (doped adj drain)) near2 region))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:47	
-	0	(wider near (gate same (gate near2 dielectric))) and ((photoresist near2 pattern) or (photo near2 (mask or masks)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:48	
-	2	wider near (gate same (gate near2 dielectric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:49	
-	0	((photoresist near2 pattern) or (photo near2 (mask or masks))) near (gate same (gate near2 dielectric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:49	
-	15514	(gate same (gate near2 dielectric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:50	
-	168	((gate same (gate near2 dielectric))) same ((photoresist near2 pattern) or (photo near2 (mask or masks)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:50	
-	48	(((gate same (gate near2 dielectric))) same ((photoresist near2 pattern) or (photo near2 (mask or masks)))) and (tft or (thin near2 film))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:52	
-	314	tapered near gate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:53	
-	66	(tapered near gate) and (tft or (thin near2 film))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/09 21:53	

-	35286	(photoresist near2 pattern) or (photo near2 (mask or masks))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 21:59
-	837644	gate or (gate near2 electrode)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:25
-	326	((photoresist near2 pattern) or (photo near2 (mask or masks))) near (gate or (gate near2 electrode))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 21:59
-	430037	tft or (thin near2 film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 21:59
-	7417	((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 22:00
-	14	((((photoresist near2 pattern) or (photo near2 (mask or masks))) near (gate or (gate near2 electrode))) and (tft or (thin near2 film))) and (((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 22:00
-	110	(((photoresist near2 pattern) or (photo near2 (mask or masks))) near (gate or (gate near2 electrode))) and (tft or (thin near2 film))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/10 22:02
-	0	6429485.URPN.	USPAT	2004/01/10 22:16
-	0	("3890632" | "5292675" | "5323042" | "5757048" | "6031249").PN.	USPAT	2004/01/10 22:17
-	430033	tft or (thin near2 film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:22
-	63417	color near2 filter	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:23
-	7417	((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 14:51
-	12891	(tft or (thin near2 film)) and (color near2 filter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 14:51
-	6941	(tft or (thin near2 film)) same (color near2 filter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 14:51

-	89	((tft or (thin near2 film)) same (color near2 filter)) and (((438/149) or (438/164) or (438/180) or (438/181) or (438/182) or (438/479) or (438/482) or (438/488) or (438/514) or (438/574) or (438/673) or (438/701) or (438/713) or (438/738) or (438/745) or (438/948)).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:01
-	1176	pigment near substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:02
-	25	(tft or (thin near2 film)) same (pigment near substrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:02
-	58114	tft or (thin near2 film near2 transistor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:22
-	1200433	(filter (color near2 filter))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:23
-	11039	(tft or (thin near2 film near2 transistor)) and ((filter (color near2 filter)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:24
-	1671185	pattern$4 etch$	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:24
-	7574	((tft or (thin near2 film near2 transistor)) and ((filter (color near2 filter)))) and (pattern$4 etch$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:24
-	837638	gate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:25
-	4855	(((tft or (thin near2 film near2 transistor)) and ((filter (color near2 filter)))) and (pattern$4 etch$)) and gate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:26
-	556043	capacitor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:26
-	2366	((((tft or (thin near2 film near2 transistor)) and ((filter (color near2 filter)))) and (pattern$4 etch$)) and gate) and capacitor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:27
-	443038	implant$3 dop$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:27
-	1550	(((((tft or (thin near2 film near2 transistor)) and ((filter (color near2 filter)))) and (pattern$4 etch$)) and gate) and capacitor) and (implant$3 dop$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:31

-	88984	polysilicon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:32
-	720	((((((tft or (thin near2 film near2 transistor)) and ((filter (color near2 filter)))) and (pattern$4 etch$)) and gate) and capacitor) and (implant$3 dop$4)) and polysilicon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/11 15:32